

Chaoquan Hu

List of Publications by Year in descending order

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66
papers

1,470
citations

257101

24
h-index

360668

35
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66
all docs

66
docs citations

66
times ranked

1465
citing authors

#	ARTICLE	IF	CITATIONS
1	Evaporation rate far beyond the input solar energy limit enabled by introducing convective flow. <i>Chemical Engineering Journal</i> , 2022, 429, 132335.	6.6	31
2	Designing hard, low-refractive-index lossy materials for super wear-resistant absorbers. <i>Materials Research Letters</i> , 2022, 10, 472-480.	4.1	2
3	3D Hydrogel Evaporator with Vertical Radiant Vessels Breaking the Trade-Off between Thermal Localization and Salt Resistance for Solar Desalination of High-Salinity. <i>Advanced Materials</i> , 2022, 34, .	11.1	73
4	Designing infrared phase change materials for colorful infrared transmittance modulators. <i>Applied Surface Science</i> , 2022, 600, 154104.	3.1	1
5	Three distinct optical-switching states in phase-change materials containing impurities: From physical origin to material design. <i>Journal of Materials Science and Technology</i> , 2021, 75, 118-125.	5.6	9
6	Biomass-Derived Carbonaceous Materials with Multichannel Waterways for Solar-Driven Clean Water and Thermoelectric Power Generation. <i>ACS Sustainable Chemistry and Engineering</i> , 2021, 9, 4571-4582.	3.2	56
7	Integration of superhydrophobicity and high durability in super-rough hard thin films. <i>Ceramics International</i> , 2021, 47, 23653-23658.	2.3	7
8	Full-color, multi-level transmittance modulators: From reflectivity/gradient absorption coupling mechanism to materials map. <i>Acta Materialia</i> , 2021, 216, 117132.	3.8	2
9	Towards highly efficient solar-driven interfacial evaporation for desalination. <i>Journal of Materials Chemistry A</i> , 2020, 8, 17907-17937.	5.2	115
10	Phase Change Materials for Nonvolatile, Solid-State Reflective Displays: From New Structural Design Rules to Enhanced Color-Changing Performance. <i>Advanced Optical Materials</i> , 2020, 8, 2000062.	3.6	12
11	“All-crystalline”-phase transition in nonmetal doped germanium-antimony-tellurium films for high-temperature non-volatile photonic applications. <i>Acta Materialia</i> , 2020, 188, 121-130.	3.8	17
12	<i>In situ</i> growth of ultra-smooth or super-rough thin films by suppression of vertical or horizontal growth of surface mounds. <i>Journal of Materials Chemistry C</i> , 2020, 8, 3248-3257.	2.7	7
13	Improving the reflectance and color contrasts of phase-change materials by vacancy reduction for optical-storage and display applications. <i>Optics Letters</i> , 2020, 45, 244.	1.7	5
14	Optical coatings of durability based on transition metal nitrides. <i>Thin Solid Films</i> , 2019, 688, 137339.	0.8	27
15	The role of structural order and stiffness in the simultaneous enhancement of optical contrast and thermal stability in phase change materials. <i>Journal of Materials Chemistry C</i> , 2019, 7, 4132-4142.	2.7	13
16	Novel SPR sensing platform based on superstructure MoS ₂ nanosheets for ultrasensitive detection of mercury ion. <i>Sensors and Actuators B: Chemical</i> , 2019, 284, 589-594.	4.0	47
17	Understanding phase-change materials with unexpectedly low resistance drift for phase-change memories. <i>Journal of Materials Chemistry C</i> , 2018, 6, 3387-3394.	2.7	20
18	New design for highly durable infrared-reflective coatings. <i>Light: Science and Applications</i> , 2018, 7, 17175-17175.	7.7	37

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19	Tribochemistry dependent tribological behavior of superhard TaC/SiC multilayer films. <i>Surface and Coatings Technology</i> , 2018, 337, 492-500.	2.2	29
20	Structural evolution and dielectric properties of Nd and Mn co-doped BaTiO ₃ ceramics. <i>Journal of Alloys and Compounds</i> , 2018, 760, 31-41.	2.8	43
21	Surface roughening transition induced by phase transformation in hafnium nitride films. <i>Surface and Coatings Technology</i> , 2017, 320, 414-420.	2.2	3
22	Improving electrical conductivity and wear resistance of hafnium nitride films via tantalum incorporation. <i>Ceramics International</i> , 2017, 43, 8517-8524.	2.3	12
23	Combined effect of ion bombardment and nitrogen incorporation on structure, mechanical and optical properties of amorphous Ge ₂ Sb ₂ Te ₅ films. <i>Vacuum</i> , 2017, 141, 32-40.	1.6	2
24	Oxygen vacancies dependent phase transition of Y ₂ O ₃ films. <i>Applied Surface Science</i> , 2017, 410, 470-478.	3.1	31
25	Improved multi-level data storage properties of germanium-antimony-tellurium films by nitrogen doping. <i>Scripta Materialia</i> , 2017, 141, 120-124.	2.6	21
26	Highly hard yet toughened bcc-W coating by doping unexpectedly low B content. <i>Scientific Reports</i> , 2017, 7, 9353.	1.6	15
27	N dependent tribochemistry: Achieving superhard wear-resistant low-friction TaC x N y films. <i>Surface and Coatings Technology</i> , 2017, 328, 378-389.	2.2	23
28	Optical reflectivity and hardness improvement of hafnium nitride films via tantalum alloying. <i>Applied Physics Letters</i> , 2016, 109, 232102.	1.5	8
29	Ion-bombardment-induced reduction in vacancies and its enhanced effect on conductivity and reflectivity in hafnium nitride films. <i>Applied Physics A: Materials Science and Processing</i> , 2016, 122, 1.	1.1	3
30	Structural evolution and optical properties of hydrogenated germanium carbonitride films. <i>Vacuum</i> , 2016, 129, 23-30.	1.6	2
31	Transformation of electronic properties and structural phase transition from HfN to Hf ₃ N ₄ . <i>Journal of Physics Condensed Matter</i> , 2015, 27, 225501.	0.7	7
32	Identification and thermodynamic mechanism of the phase transition in hafnium nitride films. <i>Acta Materialia</i> , 2015, 90, 59-68.	3.8	31
33	Hardness and optical gap enhancement of germanium carbon films by nitrogen incorporation. <i>Thin Solid Films</i> , 2015, 584, 208-213.	0.8	5
34	Negative effect of vacancies on cubic symmetry, hardness and conductivity in hafnium nitride films. <i>Scripta Materialia</i> , 2015, 108, 141-146.	2.6	25
35	Structure, mechanical and tribological properties of HfCx films deposited by reactive magnetron sputtering. <i>Applied Surface Science</i> , 2015, 327, 68-76.	3.1	30
36	Nature of Tunable Optical Reflectivity of Rocksalt Hafnium Nitride Films. <i>Journal of Physical Chemistry C</i> , 2014, 118, 20511-20520.	1.5	23

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37	On the nature of point defect and its effect on electronic structure of rocksalt hafnium nitride films. <i>Acta Materialia</i> , 2014, 81, 315-325.	3.8	31
38	The AlN layer thickness dependent coherent epitaxial growth, stress and hardness in NbN/AlN nanostructured multilayer films. <i>Surface and Coatings Technology</i> , 2013, 235, 367-375.	2.2	24
39	Relationship between dielectric coefficient and Urbach tail width of hydrogenated amorphous germanium carbon alloy films. <i>Applied Physics Letters</i> , 2012, 101, 042109.	1.5	10
40	Effects of substrate bias voltage on the microstructure, mechanical properties and tribological behavior of reactive sputtered niobium carbide films. <i>Surface and Coatings Technology</i> , 2012, 212, 185-191.	2.2	47
41	Field emission properties of vertically aligned thin-graphite sheets/graphite-encapsulated Cu particles. <i>Applied Surface Science</i> , 2012, 258, 6930-6937.	3.1	9
42	Influence of the residual stress on the nanoindentation-evaluated hardness for zirconium nitride films. <i>Surface and Coatings Technology</i> , 2012, 206, 3250-3257.	2.2	31
43	Structure, mechanical property, and tribological behavior of c-NbN/CNx multilayers grown by magnetron sputtering. <i>Surface and Coatings Technology</i> , 2012, 206, 4040-4045.	2.2	18
44	Modulation periodicity dependent structure, stress, and hardness in NbN/W ₂ N nanostructured multilayer films. <i>Journal of Applied Physics</i> , 2011, 109, .	1.1	12
45	Role of carbon in the formation of hard Ge _{1-x} C _x thin films by reactive magnetron sputtering. <i>Physica B: Condensed Matter</i> , 2011, 406, 2658-2662.	1.3	12
46	Preferred orientation, phase transition and hardness for sputtered zirconium nitride films grown at different substrate biases. <i>Surface and Coatings Technology</i> , 2011, 205, 2865-2870.	2.2	42
47	Ar plasma treatment on few layer graphene sheets for enhancing their field emission properties. <i>Journal Physics D: Applied Physics</i> , 2010, 43, 055302.	1.3	69
48	Increasing sp ³ hybridized carbon atoms in germanium carbide films by increasing the argon ion energy and germanium content. <i>Journal Physics D: Applied Physics</i> , 2010, 43, 135103.	1.3	18
49	Effects of bonding structure from niobium carbide buffer layer on the field electric emission properties of a-C films. <i>Journal of Applied Physics</i> , 2009, 105, 074318.	1.1	1
50	Relatively low temperature synthesis of hexagonal tungsten carbide films by N doping and its effect on the preferred orientation, phase transition, and mechanical properties. <i>Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films</i> , 2009, 27, 167-173.	0.9	19
51	Field electron emission enhancement of amorphous carbon through a niobium carbide buffer layer. <i>Journal of Applied Physics</i> , 2009, 105, .	1.1	2
52	Effects of nitrogen flow rate on the preferred orientation and phase transition for niobium nitride films grown by direct current reactive magnetron sputtering. <i>Journal Physics D: Applied Physics</i> , 2009, 42, 035304.	1.3	27
53	Annealing effects on the bonding structures, optical and mechanical properties for radio frequency reactive sputtered germanium carbide films. <i>Applied Surface Science</i> , 2009, 255, 3552-3557.	3.1	26
54	Stress induced preferred orientation and phase transition for ternary WC _x Ny thin films. <i>Applied Surface Science</i> , 2009, 255, 8164-8170.	3.1	7

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55	Structure and mechanical properties of $\hat{\Gamma}$ -NbN/SiN _x and $\hat{\Gamma}$ - $\hat{\Gamma}$ ² -NbN/SiN _x nano-multilayer films deposited by reactive magnetron sputtering. <i>Surface and Coatings Technology</i> , 2009, 203, 1702-1708.	2.2	28
56	Effects of bias voltage and annealing on the structure and mechanical properties of WC _{0.75} N _{0.25} thin films. <i>Journal of Alloys and Compounds</i> , 2009, 486, 357-364.	2.8	20
57	Structures, mechanical properties and thermal stability of TiN/SiN _x multilayer coatings deposited by magnetron sputtering. <i>Journal of Alloys and Compounds</i> , 2009, 486, 515-520.	2.8	28
58	Multilayer antireflective and protective coatings comprising amorphous diamond and amorphous hydrogenated germanium carbide for ZnS optical elements. <i>Thin Solid Films</i> , 2008, 516, 3117-3122.	0.8	22
59	Interfacial fracture for TiN/SiN _x nano-multilayer coatings on Si(111) characterized by nanoindentation experiments. <i>Materials Science & Engineering A: Structural Materials: Properties, Microstructure and Processing</i> , 2008, 494, 324-328.	2.6	18
60	Effects of substrate bias on the preferred orientation, phase transition and mechanical properties for NbN films grown by direct current reactive magnetron sputtering. <i>Journal of Applied Physics</i> , 2008, 104, .	1.1	43
61	Field electron emission enhancement of amorphous carbon through a niobium buffer layer. <i>Journal of Applied Physics</i> , 2008, 103, 114314.	1.1	4
62	Effects of radio frequency power on the chemical bonding, optical and mechanical properties for radio frequency reactive sputtered germanium carbide films. <i>Journal Physics D: Applied Physics</i> , 2006, 39, 5074-5079.	1.3	17
63	Effects of the chemical bonding on the optical and mechanical properties for germanium carbide films used as antireflection and protection coating of ZnS windows. <i>Journal of Physics Condensed Matter</i> , 2006, 18, 4231-4241.	0.7	31
64	Ge $\hat{\Gamma}$ -xCx double-layer antireflection and protection coatings. <i>Applied Surface Science</i> , 2006, 252, 8135-8138.	3.1	22
65	Chemical bonding of a-Ge $\hat{\Gamma}$ -xCx:H films grown by RF reactive sputtering. <i>Vacuum</i> , 2004, 77, 63-68.	1.6	20
66	Thermal stability of magnetron sputtering amorphous carbon nitride films. <i>Vacuum</i> , 2003, 72, 233-239.	1.6	18